IN THE CLAIMS:

Please cancel Claims 2 through 6, without prejudice.

1. (Currently amended) A semiconductor material having a equilibrium dopant
solubility of boron or indium of greater than 1% wherein said semiconductor material
comprises silicon grown on a Aluminum Phosphate (AIP) substrate along a (001) direction.
2. (Canceled)

- 3. (Canceled)
- 4. (Canceled).
- 5. (Canceled)
- 6. (Canceled)
- 7. (Currently Amended) The semiconductor material of claim 1 comprising A \underline{a} p-type semiconductor comprising silicon and a dopant comprising boron or indium.
- 8. (Currently Amended) The semiconductor <u>material</u> of Claim 7 wherein said dopant includes boron and said semiconductor comprises S:B₃ SiB₃.